Supporting information

Synthesis and optoelectronic properties of reduced graphene oxide/InP quantum dot hybrids

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Figure S1

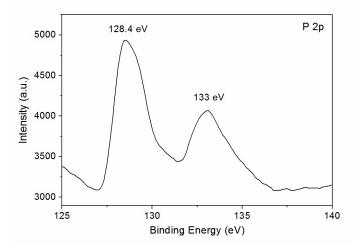


Figure S1. High resolution P_{2p} XPS spectrum of the rGO/InP QD hybrids

Figure S2

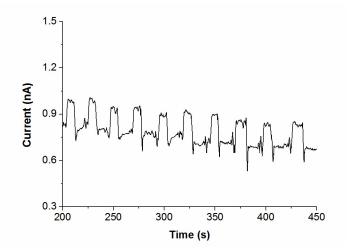


Figure S2. The current response of pure InP QDs versus time under intermittent blue light irradiation with a voltage of 1 V.